

Patent Abstracts of Japan

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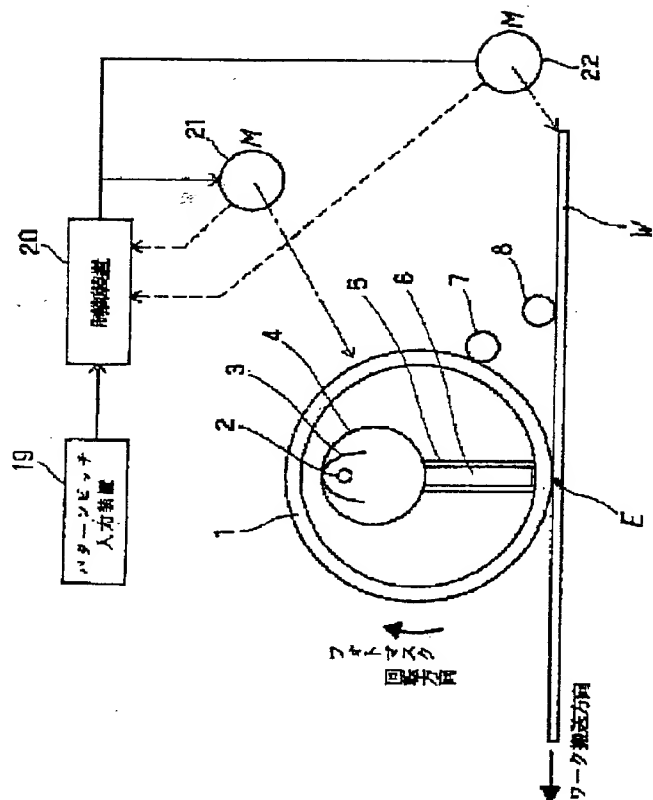
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APPLICANT : ADTEC ENGINEERING CO LTD;

INVENTOR : IDA RYOICHI;

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TITLE : ALIGNER



ABSTRACT : PROBLEM TO BE SOLVED: To provide an aligner capable of realizing consecutive exposure.

SOLUTION: A cylindrical photomask 1 is rotated, and a work W is carried in synchronization with the rotation of the photomask 1 and exposed at an exposing position E by an exposing light source 2 provided in the photomask 1. The pattern pitch of a film mask 10 is previously measured and the rotation of a cylindrical body 11 is controlled in according with the pattern pitch.

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